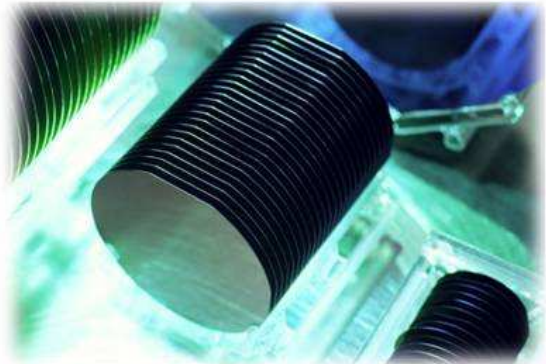




Gallium Nitride (GaN) Template

Marco-Defect Density <math><10/cm^2</math>
Substrate Diameter 3"
Thickness 20 μ m



GaN templates refer to a thin layer of single crystalline GaN, typically with thickness less than 100 microns, epitaxial grown on a foreign substrate, e.g. sapphire. Comparing with free standing GaN substrate, GaN template is only an alternative solution to device makers and its technical merit is limited. Upon high volume and low cost production, however, GaN template can replace sapphire in LED manufacturing, enhancing up to 50% capacity of downstream MOCVD reactors. Furthermore, GaN template usually has lower dislocation density than MOCVD GaN grown on sapphire. This is a favorable factor for UV devices as it is more sensitive to dislocation density than blue LED does.

Gallium Nitride (GaN) Template Specifications

Thickness (μ m)	50	Substrate Diameter	3"
Off-Cut Angle (Degree)	1	GaN Template Line	semi-insulating
Marcodefect Density:	<math><10/cm^2</math>	Thickness Variation ($\pm \mu$ m)	2.5
Carrier concentration (cm^{-3})	-	Resistivity ($\Omega \cdot cm$)	10^9-10^{12}
FWHM of (102) XRD arcsec	<math><300</math>	Dislocation density	$5E+7 cm^{-2}$
Surface finishing	as grown	Substrates	sapphire
Bow (μ m)	300	Package (cell cassette)	25

GaN Template Marco-Defect Density <math><10/cm^2</math> Substrate Diameter 3" Thickness 50 μ m